DOCKET NO.: UPN-4377 **Application No.:** 10/817,532

Office Action Dated: August 11, 2006

This listing of claims will replace all prior versions, and listings, of claims in the application.

Listing of Claims:

1. (Original) A process for preparing a compound of formula I:

wherein:

 R^0 is C_{1-6} alkyl, C_{2-6} alkenyl, C_{2-6} alkynyl, $(CH_2)_r(C_{3-6}$ cycloalkyl), $(CH_2)_r(aryl)$ or $(CH_2)_r(heterocycle)$, wherein r is selected from 0, 1, 2, 3, and 4;

 R^1 , R^2 , R^3 , R^6 , R^7 and R^8 are independently H or C_{1-10} alkyl;

R⁴ is an acid labile hydroxyl protecting group;

 R^5 is an oxidatively labile hydroxyl protecting group; each R^9 is independently C_{6-14} aryl;

Q is H or an acid labile hydroxyl protecting group wherein the hydroxyl protecting group has a mass of 135 Daltons or less and is unbranched at the atom bonded to the oxygen of the hydroxyl group being protected; and X is halogen;

comprising contacting a compound of formula II:

wherein:

 R^0 is C_{1-6} alkyl, C_{2-6} alkenyl, C_{2-6} alkynyl, $(CH_2)_r(C_{3-6}$ cycloalkyl), $(CH_2)_r(aryl)$ or $(CH_2)_r(heterocycle)$, wherein r is selected from 0, 1, 2, 3, and 4;

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 R^1 , R^2 , R^3 , R^6 , R^7 and R^8 are independently H or C_{1-10} alkyl;

R⁴ is an acid labile hydroxyl protecting group;

R⁵ is an oxidatively labile hydroxyl protecting group;

Q is H or an acid labile hydroxyl protecting group wherein the hydroxyl protecting group has a mass of 135 Daltons or less and is unbranched at the atom bonded to the oxygen of the hydroxyl group being protected; and

X is halogen;

at a pressure of less than about 10,000 psi with a phosphine of formula $P(R^9)_3$ wherein each R^9 is independently C_{6-14} aryl;

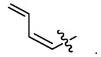
for a time and under conditions sufficient to prepare the compound of formula I.

- 2. (Original) A process according to claim 1 wherein Q is methoxymethyl, methylthiomethyl, 2-methoxyethoxymethyl, acetyl, benzyloxymethyl, 2-(trimethylsilyl)ethoxymethyl or allyl.
- 3. (Original) A process according to claim 2 wherein Q is methoxymethyl.
- 4. (Original) A process according to claim 1 wherein the X moiety of the compound of formula II is iodo.
- 5. (Original) A process according to claim 1 further comprising a base.
- 6. (Original) A process according to claim 5 wherein the base is non-nucleophilic.
- 7. (Original) A process according to claim 6 wherein the base is isopropyldiethylamine.
- 8. (Original) A process according to claim 1 wherein the reaction is carried out at essentially atmospheric pressure.
- 9. (Original) A process according to claim 1 wherein R⁰ is alkenyl.

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10. (Original) A process according to claim 9 wherein R^0 is:



- 11. (Original) A process according to claim 1 wherein R^1 , R^2 , R^3 , R^6 , R^7 and R^8 are independently H or C_{1-3} alkyl.
- 12. (Original) A process according to claim 1 wherein R^1 , R^2 , R^7 and R^8 are methyl and R^3 and R^6 are each independently H or methyl.
- 13. (Original) A process according to claim 1 wherein R¹, R², R³, R⁶, R⁷ and R⁸ are methyl.
- 14. (Original) A process according to claim 1 wherein R^1 , R^2 , R^3 , R^7 and R^8 are methyl and R^6 is H.
- 15. (Original) A process according to claim 1 wherein the reaction temperature is in the range of about 0 to about 200°C.
- 16. (Original) A process according to claim 15 wherein the reaction temperature is in the range of about 20 to about 140°C.
- 17. (Original) A process according to claim 1 wherein the reaction pressure is in the range from about ambient to about 10,000 psi.
- 18. (Original) A process according to claim 17 wherein the reaction pressure is essentially ambient.
- 19. (Original) A process according to claim 1 wherein at least one of R⁹ is phenyl.
- 20. (Original) A process according to claim 1 wherein R⁵ is *para*-methoxybenzyl.

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- 21. (Original) A process according to claim 1 wherein R^4 is $(R^{16})_3Si$ -, and wherein each R^{16} is independently C_{1-6} alkyl.
- 22. (Original) A process according to claim 21 wherein R⁴ is tert-butyldimethylsilyl.
- 23. (Original) A compound of the formula I:

wherein:

 R^0 is C_{1-6} alkyl, C_{2-6} alkenyl, C_{2-6} alkynyl, $(CH_2)_r(C_{3-6}$ cycloalkyl), $(CH_2)_r(aryl)$ or $(CH_2)_r(heterocycle)$, wherein r is selected from 0, 1, 2, 3, and 4;

 R^1 , R^2 , R^3 , R^6 , R^7 and R^8 are independently H or $C_{1\text{--}10}$ alkyl;

R⁴ is an acid labile hydroxyl protecting group;

R⁵ is an oxidatively labile hydroxyl protecting group;

each R⁹ is independently C₆₋₁₄ aryl;

Q is H or an acid labile hydroxyl protecting group wherein the hydroxyl protecting group has a mass of 135 Daltons or less and is unbranched at the atom bonded to the oxygen of the hydroxyl group being protected; and X is halogen.

24-33. (Canceled)